

Benjamin C. Anderson

Law Clerk, Admission Pending

bcanderson@desmaraisllp.com

NEW YORK Phone: 212-808-1028 Fax: 212-351-3401

Mr. Anderson's practice focuses on patent and other technology-related litigation and counseling.

During law school, Mr. Anderson performed pro bono legal work as a student attorney in NYU Law's Science, Health, and Information Clinic, where he advocated for transparency and government disclosure of settlement terms in a first-of-its-kind patent infringement action brought by the federal government. While at the clinic, Mr. Anderson also assisted in drafting multiple amicus briefs on issues of patent, trade secrecy, and constitutional takings law at the United States Court of Appeals for the Federal Circuit, among other work. Mr. Anderson served as Managing Editor for the *NYU Journal of Intellectual Property and Entertainment Law*, and has written covering issues at the intersection of artificial intelligence and copyright law.

Prior to law school, Mr. Anderson served for four years as a patent examiner at the US Patent and Trademark Office, examining applications across fields including materials science, metallurgy, and additive manufacturing.

Prior Experience

- Summer Associate, Desmarais LLP, New York, NY, 2025
- Summer Associate, Kirkland & Ellis LLP, New York, NY, 2024-2025

Clerk & Government Experience

- Patent Examiner, United States Patent and Trademark Office, Alexandria, VA, 2019-2023

Other Distinctions

- NYU Journal of Intellectual Property & Entertainment Prize, 2026

News & Publications

- Benjamin Anderson, *Reasonable Intelligence: How Should Platforms be Held Accountable for AI-Assisted Copyright Infringement?* 15 N.Y.U. J. Intell. Prop. & Ent. L. 436 (2026).
- Esfahani, M.R., Koutahzadeh, N., Esfahani, A.R., Firouzjaei, M.D., Anderson, B.C., and Peck, L. (2019). *A novel gold nanocomposite*

EDUCATION

New York University School of Law, J.D., 2026; *cum laude*; Managing Editor, *Journal of Intellectual Property and Entertainment Law*; Desmarais LLP Scholarship (full tuition merit-based scholarship)

The University of Alabama, B.S., Chemical Engineering and Mathematics, 2019; *summa cum laude*; Outstanding Senior (2019); AIChE Chilton Award, awarded to the outstanding ChE student of the junior class (2018); Presidential Scholarship; Engineering Leadership Scholarship

ADMISSIONS

New York, Pending

membrane with enhanced permeation, rejection and self-cleaning ability. Journal of Membrane Science, 573, 309–319.